

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	666636	interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L2	12454	wavefront	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L3	45793	projection with system	US-PGPUB; USPAT	OR	ON	2005/07/27 17:22
L4	922	(projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L5	0	"20020012124".URPN.	USPAT	OR	ON	2005/07/27 17:15
L6	0	"20020080366".URPN.	USPAT	OR	ON	2005/07/27 17:15
L7	0	"20020024643".URPN.	USPAT	OR	ON	2005/07/27 17:15
L8	432778	projection	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L9	77614	interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L10	812	wavefront	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L11	10626	projection with system	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L12	211	(interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L13	637723	wafer or substrate	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L14	6572	(interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L15	814521	wafer or substrate	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L16	3138	((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront) and (wafer or substrate)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L17	1	"6118535".PN.	USPAT	OR	OFF	2005/07/27 17:15
L18	1	"5978085".PN.	USPAT	OR	OFF	2005/07/27 17:15

L19	710	((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L20	162	"356"/\$.ccls. and (((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate))	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L21	22	"5142132".URPN.	USPAT	OR	ON	2005/07/27 17:15
L22	22	"5142132".URPN.	USPAT	OR	ON	2005/07/27 17:15
L23	117	(356/515).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L24	27	projection and ((356/515).CCLS.)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L25	305	(356/512).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L26	206	(356/511).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L27	64	projection and ((356/512).CCLS.)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L28	41	projection and ((356/511).CCLS.)	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L29	150	(356/618).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L30	3	((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate)	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L31	6	(projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L32	1188	((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront) and (wafer or substrate)) and projection	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15

L33	4	((projection) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate)	EPO; JPO; IBM_TDB	OR	ON	2005/07/27 17:15
L34	40	"5286963".URPN.	USPAT	OR	ON	2005/07/27 17:15
L35	1	"4498742".PN.	USPAT	OR	OFF	2005/07/27 17:15
L36	1	"4653903".PN.	USPAT	OR	OFF	2005/07/27 17:15
L37	1	"4682885".PN.	USPAT	OR	OFF	2005/07/27 17:15
L38	1	"4711568".PN.	USPAT	OR	OFF	2005/07/27 17:15
L39	1	"5117254".PN.	USPAT	OR	OFF	2005/07/27 17:15
L40	1	"5160962".PN.	USPAT	OR	OFF	2005/07/27 17:15
L41	3	"6061188".URPN.	USPAT	OR	ON	2005/07/27 17:15
L42	9	"6312373".URPN.	USPAT	OR	ON	2005/07/27 17:15
L43	1	"5898501".PN.	USPAT	OR	OFF	2005/07/27 17:15
L44	1	"5835217".PN.	USPAT	OR	OFF	2005/07/27 17:15
L45	1	"5805273".PN.	USPAT	OR	OFF	2005/07/27 17:15
L46	1	"5076695".PN.	USPAT	OR	OFF	2005/07/27 17:15
L47	16	"5898501".URPN.	USPAT	OR	ON	2005/07/27 17:15
L48	1	"5737079".PN.	USPAT	OR	OFF	2005/07/27 17:15
L49	1	"5563706".PN.	USPAT	OR	OFF	2005/07/27 17:15
L50	16	"5898501".URPN.	USPAT	OR	ON	2005/07/27 17:15
L51	1	"5563706".PN.	USPAT	OR	OFF	2005/07/27 17:15
L52	1	"5737079".PN.	USPAT	OR	OFF	2005/07/27 17:15
L53	1	("5898501").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L54	16	"5898501".URPN.	USPAT	OR	ON	2005/07/27 17:15
L55	714	(((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate or reticle))	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L56	660	(((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate or reticle)) and pattern	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15

L57	163	"356"/\$.ccls. and (((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate or reticle)) and pattern	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L58	175	"355"/\$.ccls. and (((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate or reticle)) and pattern	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L59	1	("6278514").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/27 17:15
L60	164	"356"/\$.ccls. and (((projection with system) and ((interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically) and wavefront)) and (wafer or substrate or reticle))	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L61	7	("5381210" "5801815" "5805273" "5828455" "5898501" "6278514" "6281966").PN.	US-PGPUB; USPAT	OR	ON	2005/07/27 17:15
L62	1	"5436692".PN.	USPAT	OR	OFF	2005/07/27 17:15
L63	21	"5805273".URPN.	USPAT	OR	ON	2005/07/27 17:15
L64	16351	(interfer or interfere or interference or interfering or interferometer or interferometric or interferometrically).clm.	US-PGPUB	OR	ON	2005/07/27 17:22
L65	4828	(projection with system).clm.	US-PGPUB	OR	ON	2005/07/27 17:22
L66	247	64 and 65	US-PGPUB	OR	ON	2005/07/27 17:22
L67	21740	(reticle or mask).clm.	US-PGPUB	OR	ON	2005/07/27 17:23
L68	89	66 and 67	US-PGPUB	OR	ON	2005/07/27 17:23
L69	41907	(expose or exposure or exposing).clm.	US-PGPUB	OR	ON	2005/07/27 17:23
L70	72	68 and 69	US-PGPUB	OR	ON	2005/07/27 17:24